

Electronic structures and photovoltaic properties of copper-, sodium- and ethylammonium-added $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite compound



THE UNIVERSITY OF
SHIGA PREFECTURE

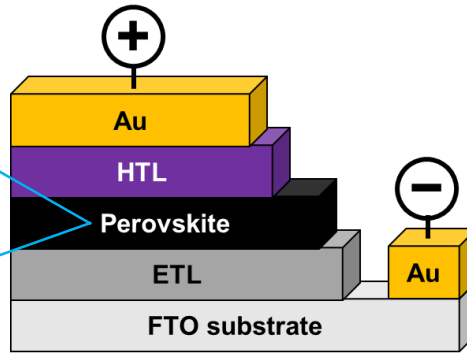
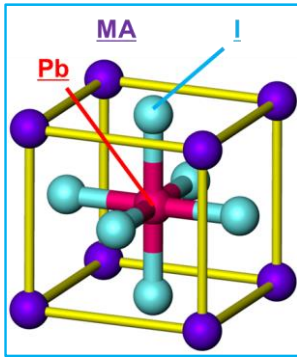
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OSAKA GAS CHEMICALS

Masanobu Okita, Sakiko Fukunishi,
Tomoharu Tachikawa, Tomoya Hasegawa

Introduction



MA : Methyl ammonium
HTL : Hole transport layer
ETL : Electron transport layer

Perovskite crystal structure

Device structure

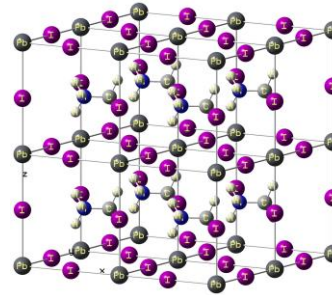
Experiment



Device fabrication

- Current-voltage characteristics
- External quantum efficiency (EQE)
- X-ray diffraction (XRD)
- Device durability

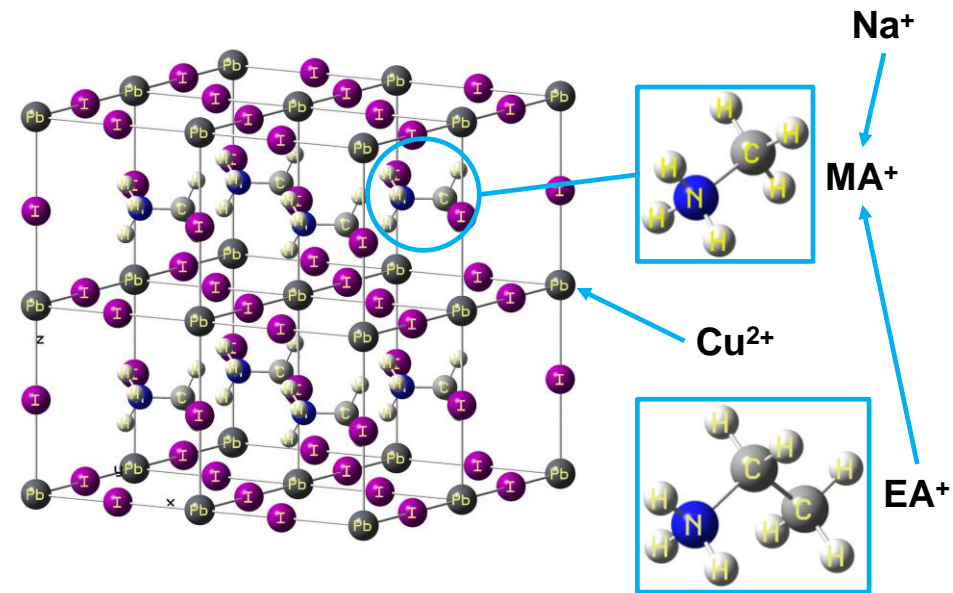
Calculation



Crystal structure modeling

- Total energy
- Band structure
- Partial density of state
- Electron density distribution

Introduction



MA : Methyl ammonium
EA : Ethyl ammonium

○ Effects of adding copper
→ Increase in particle size
Homogenization of surface morphology
K. L. Wang, *et al.* Nano Lett. 19, 5176-5184 (2019)
M. Jahandar, *et al.* Nano Energy 27, 330-339 (2016)

○ Effects of adding alkali metals
→ Decrease in hysteresis, etc.
Inherent additive effects
S. G. Kim, *et al.* J. Mater. Chem. A 7, 18807 (2019)
C. Baena, *et al.* Science 363, 627-631 (2019)

○ First-principles calculations
Copper and alkali metals substitution destabilizes crystal structure
→ Stable organic cations were introduced for stability
D. Liu, *et al.* RSC Adv. 9, 7356 (2019)
M. Mateen, *et al.* Sci. China Mater. 63, 2477-2486 (2020)

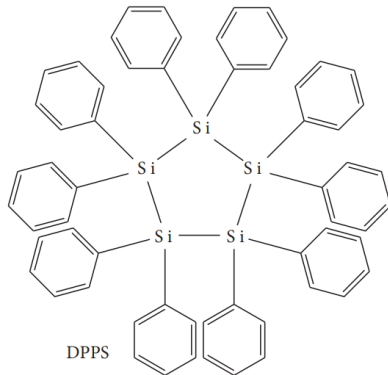
○ Purpose of this study
Investigation of the effects of adding copper, alkali metals, and organic cations to perovskite crystals through experiments and first-principles calculations

Device fabrication

Spin-coating spiro-OMeTAD solution

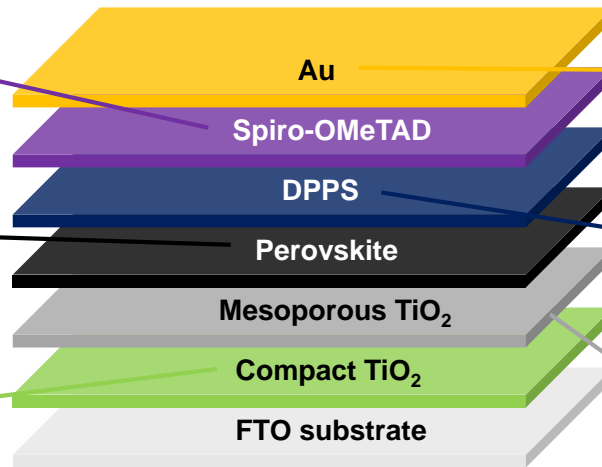
Spin-coating perovskite precursor solution

1. Spin-coating compact TiO₂ precursor solution
2. Annealing at 550 °C for 30 min



T. Oku, *et al.* *Coatings* 11, 665 (2021)

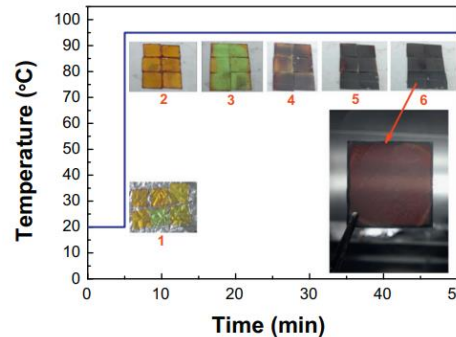
Addition of DPPS to enhance heat resistance of perovskite crystals



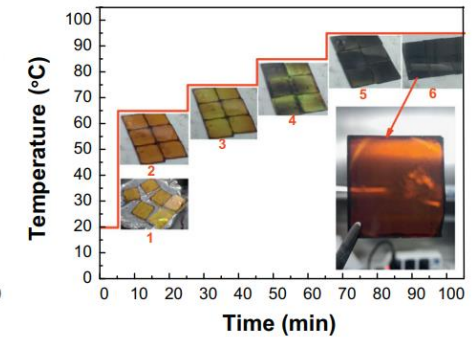
Vacuum deposition of Au

1. Spin-coating perovskite precursor solution and DPPS
2. Annealing at 90-160 °C

1. Spin-coating mesoporous TiO₂ precursor solution
2. Annealing at 550 °C for 30 min



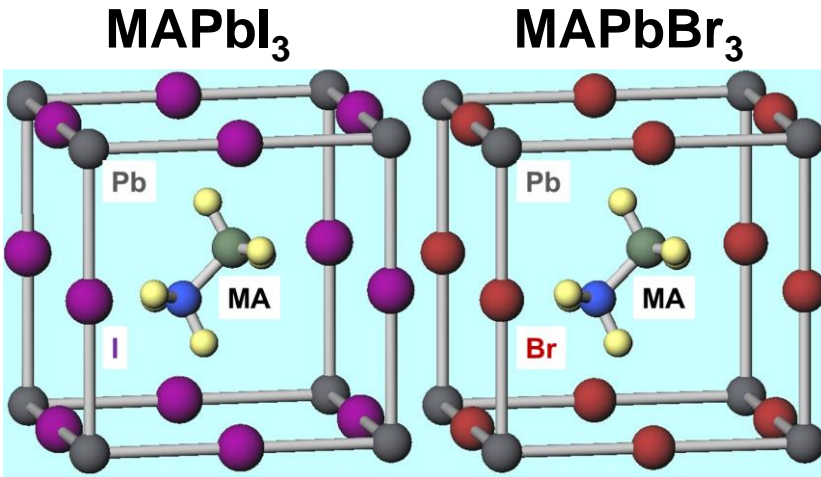
L. Huang, *et al.* *Sol. Energy Mater. Sol. Cells* 141, 377-382 (2015)



Increase of heat treatment temperature in steps to improve quality of the perovskite film

First principles calculations

Effect of Br substitution on energy gap



Model	ΔE (eV)	E_g (eV)	m_e^*/m_0	m_h^*/m_0
MAPbI ₃	0	1.51	0.071	0.100
MAPbBr ₃	-160	2.26	0.224	0.100

E : Total energy

E_g : Energy gap

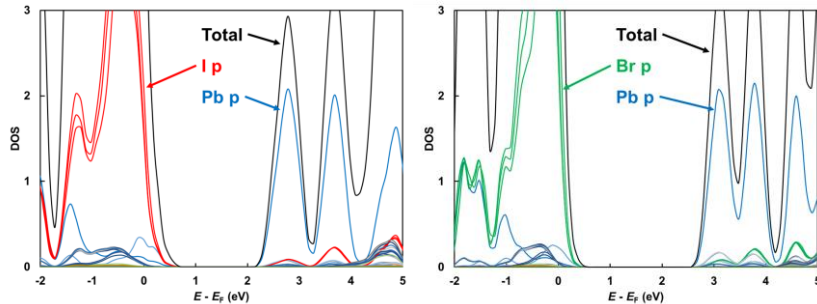
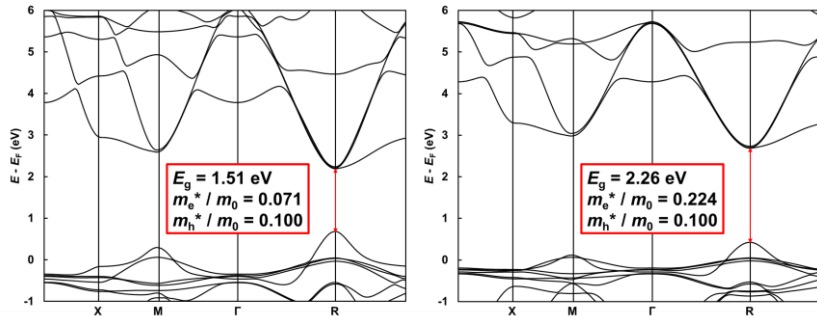
$m_e^*/m_0, m_h^*/m_0$:

Effective mass ratio of electrons and holes

$$V_{OC} \approx \frac{E_g}{q} - \frac{kT}{q} \log \left(\frac{A}{J_{SC}} \right)$$

V_{OC} : Open-circuit voltage

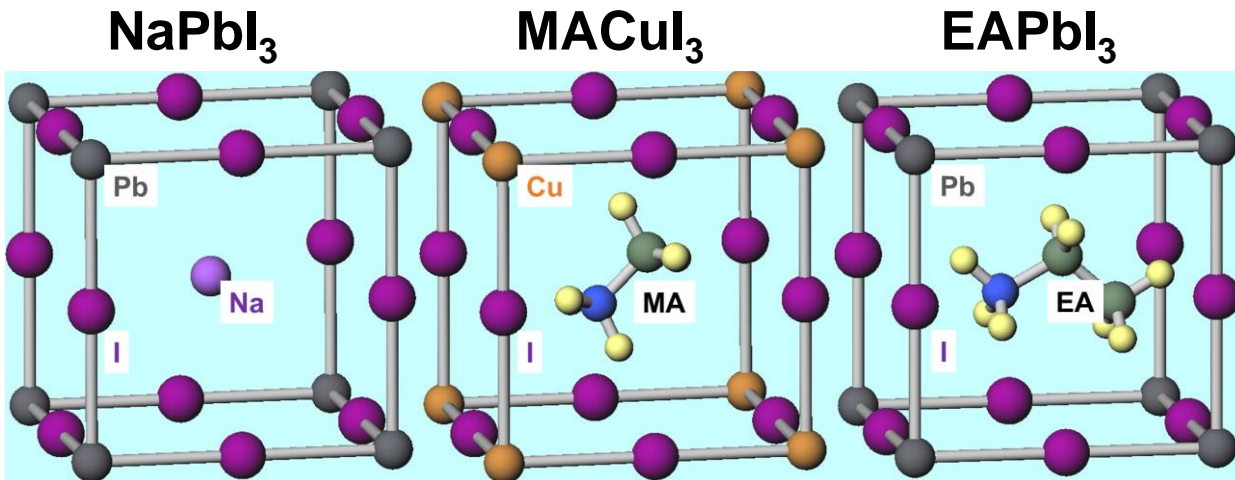
E_g : Energy gap



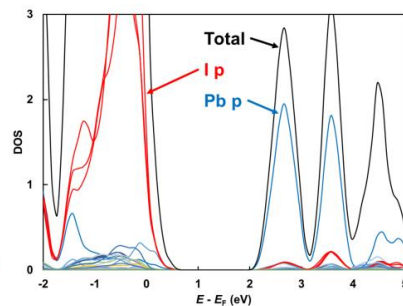
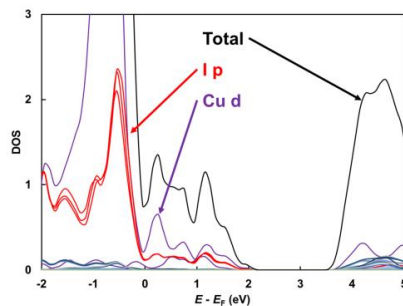
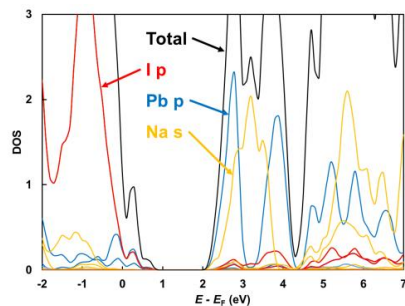
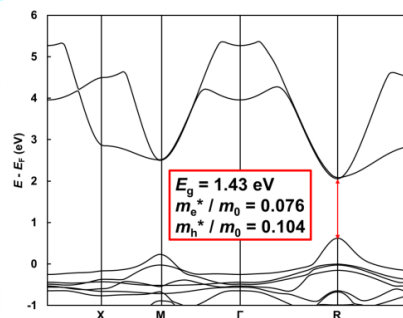
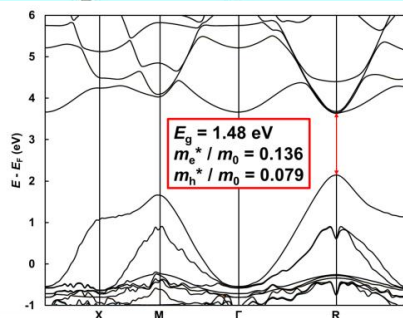
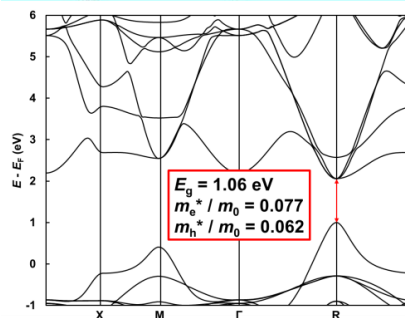
Br substitution increases E_g
 → Possibility to improve V_{OC}

First principles calculations

Effect of Cu, Na and EA on crystal structure stability



Model	ΔE (eV)
MAPbI ₃	0
NaPbI ₃	+510
MACuI ₃	+980
EAPbI ₃	-180



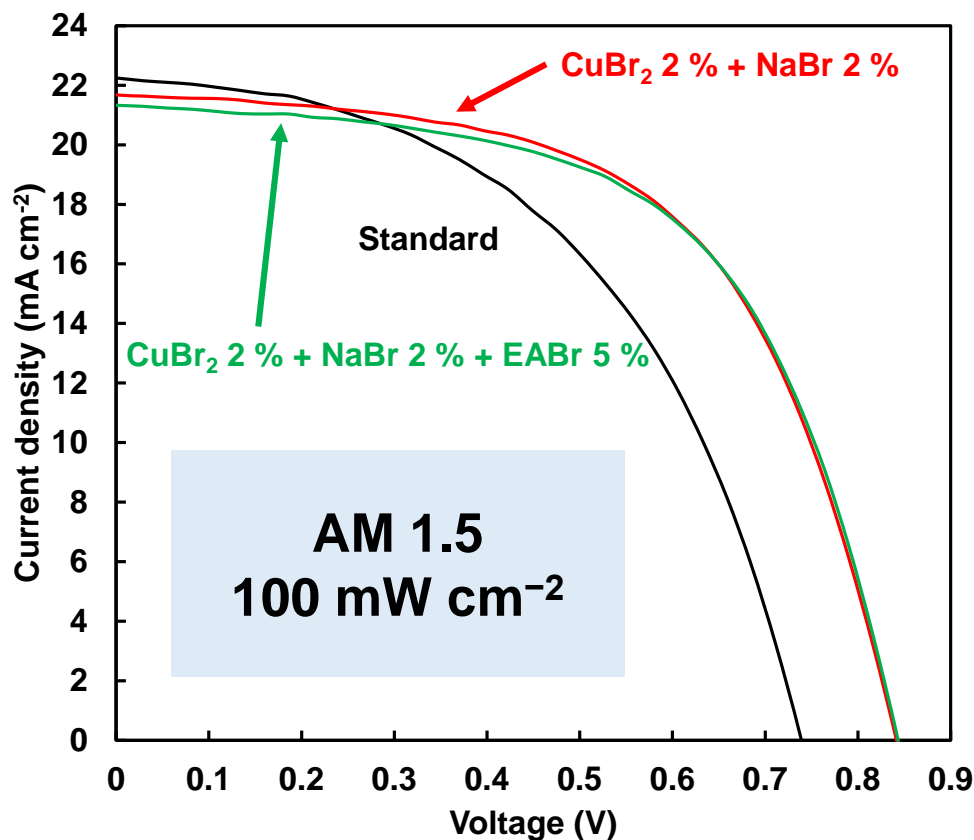
○ Cu, Na substitution
 → Destabilization of crystal structure



○ EA substitution
 → Stabilization of crystal structure

Results and discussion

J-V curves and parameters



Calculation

MAPbI₃ $E_g=1.51$ eV

MAPbBr₃ $E_g=2.26$ eV

Br substitution increases E_g

$$V_{OC} \approx \frac{E_g}{q} - \frac{kT}{q} \log\left(\frac{A}{J_{SC}}\right)$$

V_{OC} : Open circuit voltage

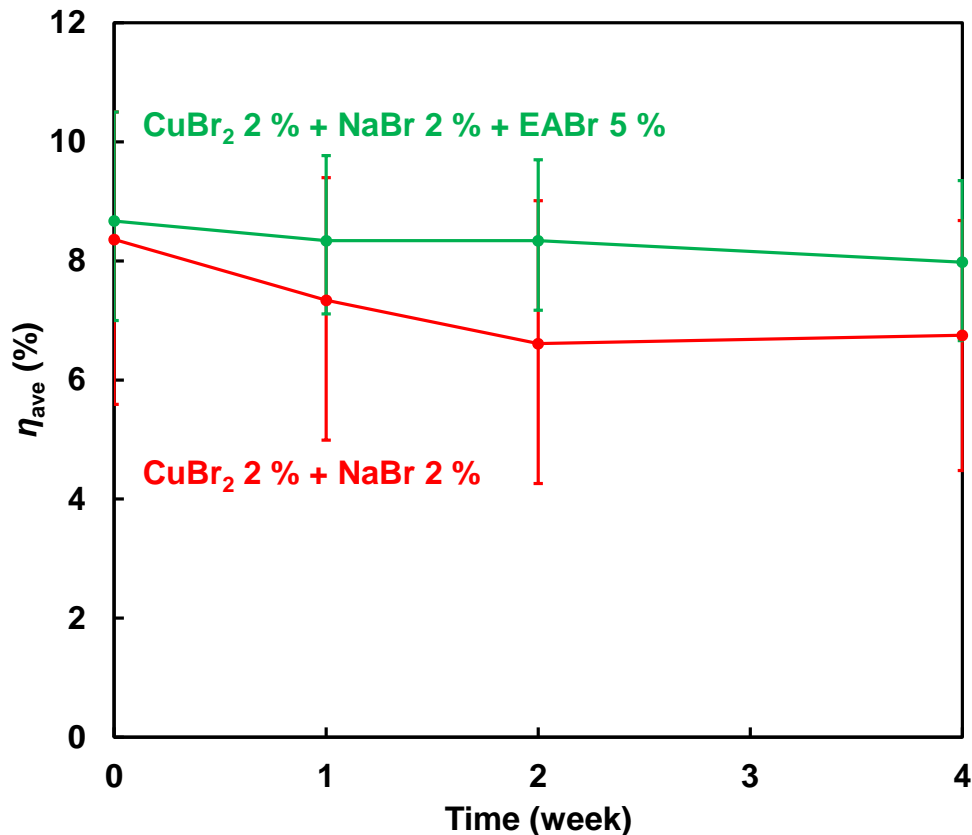
E_g : Energy gap

Increase of E_g contributes to higher V_{OC}

Devices	J_{SC} (mA cm ⁻²)	V_{OC} (V)	FF	R_s (Ω cm ²)	R_{sh} (Ω cm ²)	η (%)	η_{ave} (%)	E_g (eV)
Standard	22.2	0.739	0.497	4.18	383	8.17	5.82	1.55
CuBr ₂ 2 % NaBr 2 %	21.7	0.841	0.578	5.93	594	10.5	8.36	1.56
Cu 2 % Na 2 % EABr 5 %	21.3	0.843	0.585	5.12	558	10.5	8.67	1.57

Results and discussion

Total energies and device durability



Calculation

○ Total energy (keV cell⁻¹)

MAPbI₃ : -3.50

NaPbI₃ : -2.99

MACuI₃ : -2.52

EAPbI₃ : -3.68

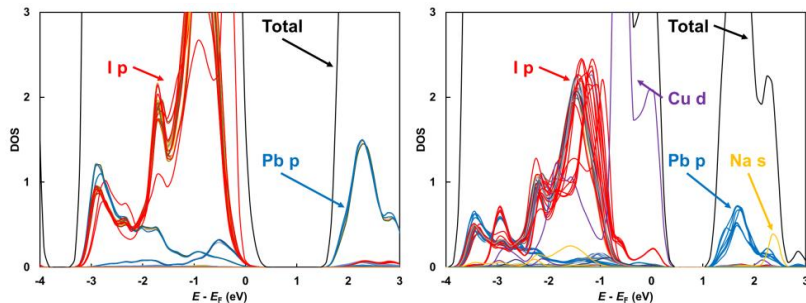
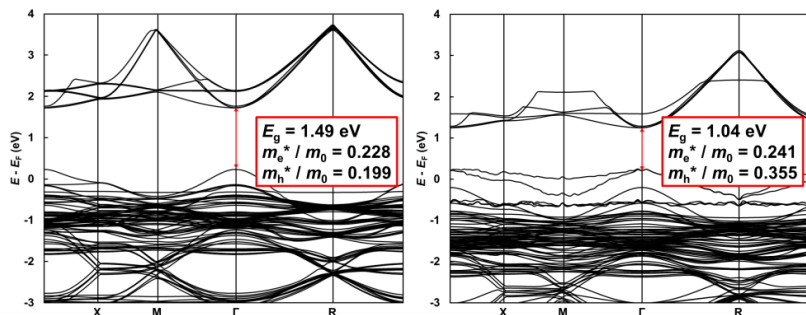
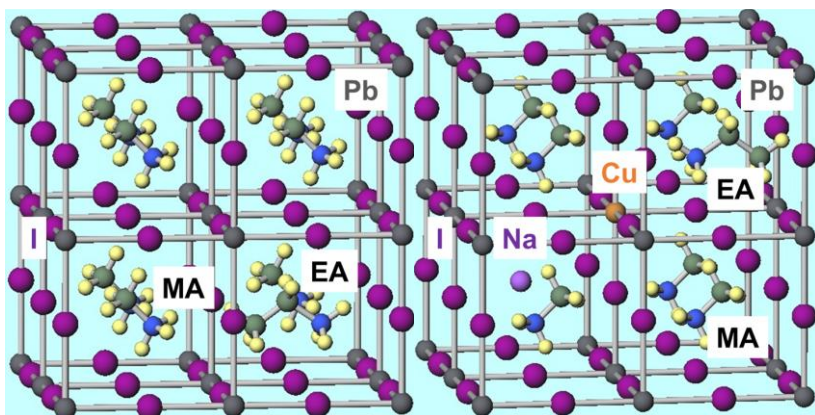
**Stabilization of crystal structure
by EA substitution
→ Enhanced device durability**

Devices	η_{ave} (%)				Stability (%)
	0 week	1 week	2 weeks	4 weeks	
CuBr ₂ 2 % NaBr 2 %	8.36	7.34	6.61	6.75	79.1
Cu 2 % Na 2 % EABr 5 %	8.67	8.34	8.34	7.98	96.2

First principles calculations

Results of first-principles calculations using the partial substitution structure model

EA 12.5 % EA Cu Na 12.5 %



Model	ΔE (eV)	E_g (eV)	m_e^*/m_0	m_h^*/m_0
EA 12.5 %	0	1.49	0.228	0.199
EA Cu Na 12.5 %	+200	1.04	0.241	0.355

m_h^*/m_0 : Effective mass ratio of holes

○ Cu and Na substitution

→ Decrease in E_g
Increase in m_h^*

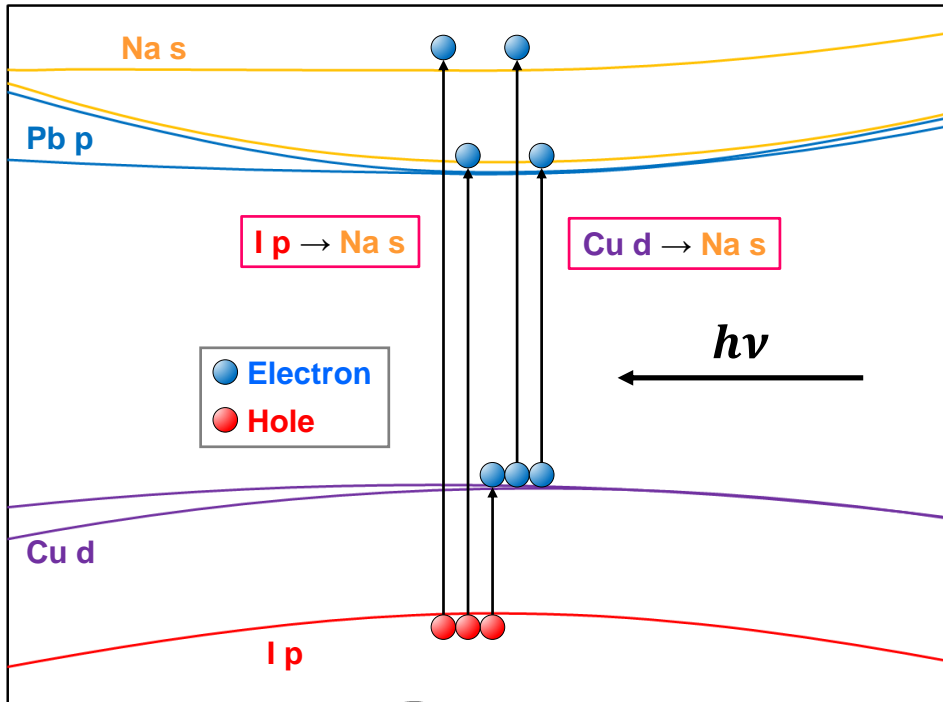
Experiment

○ Cu addition

E_g : 1.55 → 1.56 eV, η : 8.17 → 10.5 %
→ Results of experiments and calculations don't correspond

Results and discussion

Model of the excitation process



Experiment

○ Cu addition
 $E_g : 1.55 \rightarrow 1.56 \text{ eV}$
 $\eta : 8.17 \rightarrow 10.5 \%$

Calculation

○ Cu substitution
 $E_g : 1.49 \rightarrow 1.00 \text{ eV}$
 $m_h^*/m_0 : 0.199 \rightarrow 0.352$

The Cu d orbital level functions as an acceptor level
 $I - p \rightarrow Cu - d$
▶▶ Acceleration of carrier generation
 $Cu - d, I - p \rightarrow Na - s$
▶▶ Decrease in carrier recombination

Conclusion

- **Halogen substitution**
→ **Affects energy gap**

- ▶▶▶ Correspondence between calculation and experimental results

- **Stabilization of crystal structure by EA substitution**
→ **Enhanced device durability**

- ▶▶▶ Possibility of predicting durability by first-principles calculations

- **Co-adding effects of Cu and Na are discussed using the band structure**

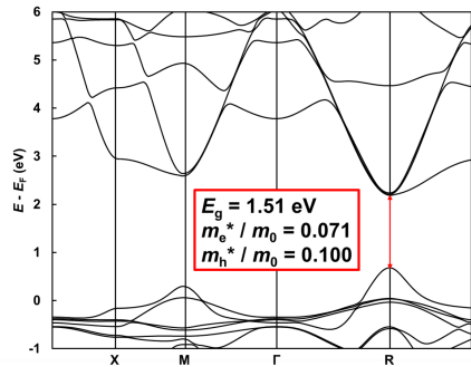
- ▶▶▶ Possibility of accelerated carrier generation and reduced loss of generated carriers

- ◎ **A method to study the effects of adding compounds using first-principles calculations and experimental results**

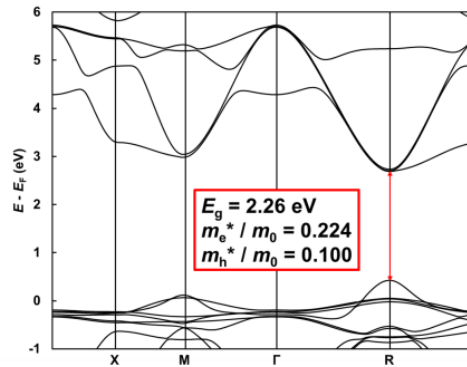
- ▶▶▶ Applicable for use with other alkali metals and organic cations

Supporting information

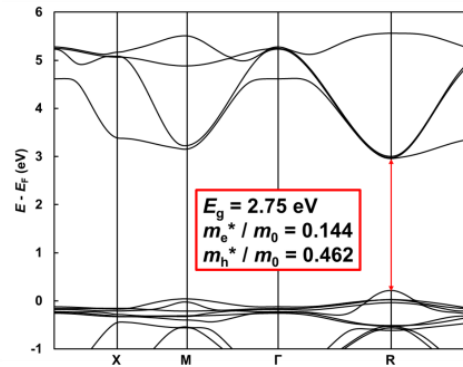
MAPbI₃



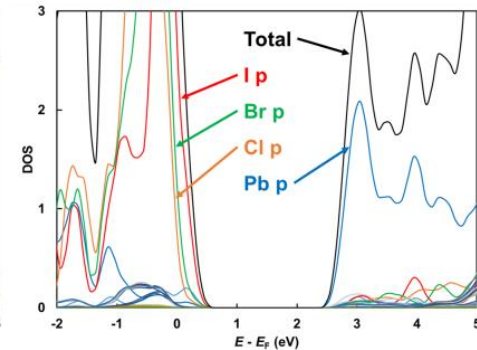
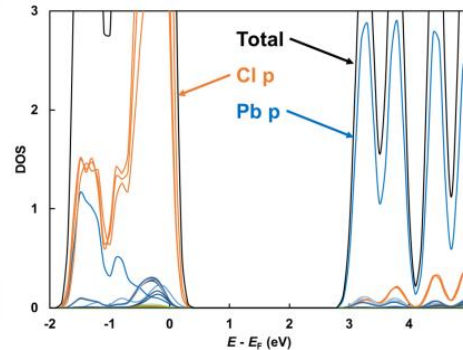
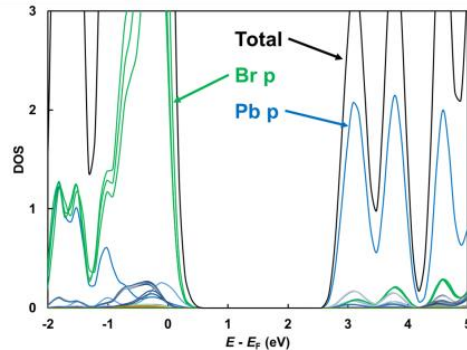
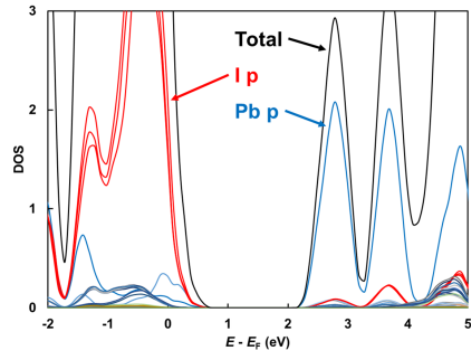
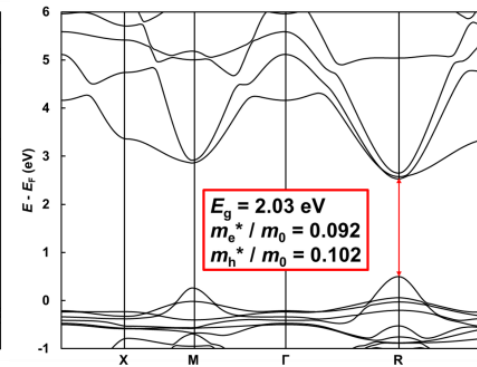
MAPbBr₃



MAPbCl₃



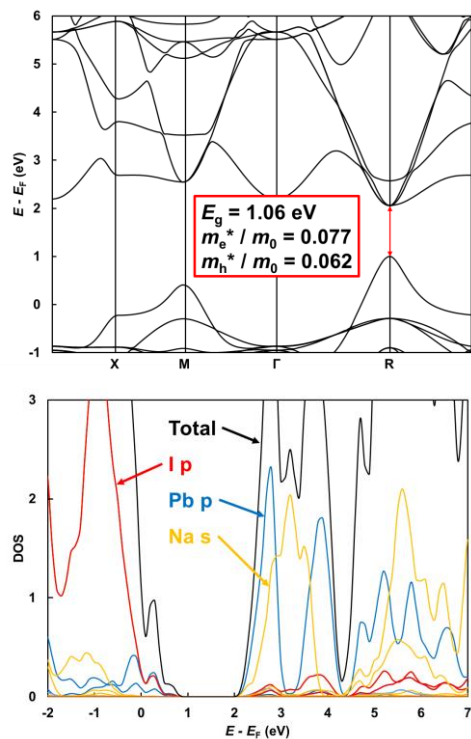
MAPbClBr



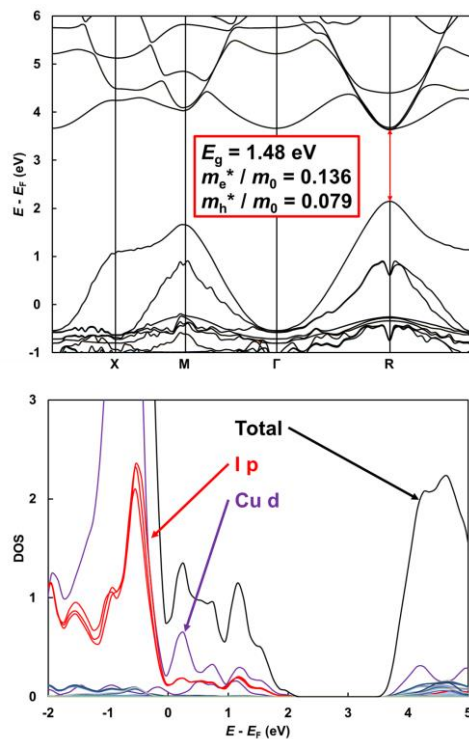
Model	Total energy (keV)	Energy gap (eV)	m_e^* / m_0	m_h^* / m_0
MAPbI ₃	-3.50	1.51	0.071	0.100
MAPbBr ₃	-3.66	2.26	0.224	0.100
MAPbCl ₃	-3.78	2.75	0.144	0.462
MAPbClBr	-3.64	2.03	0.092	0.102

Supporting information

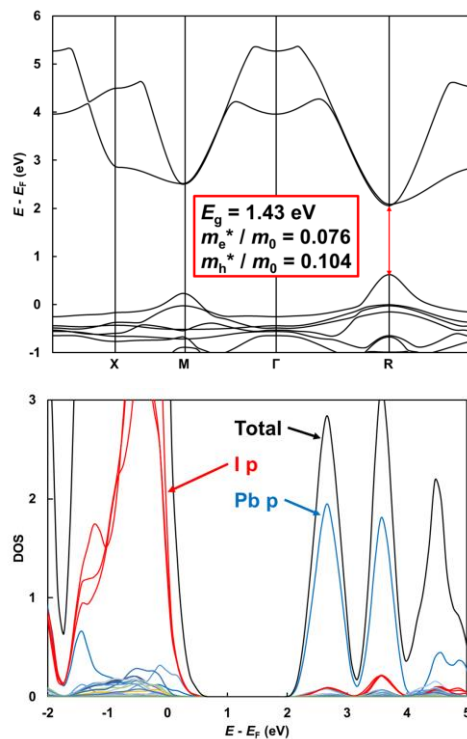
NaPbI₃



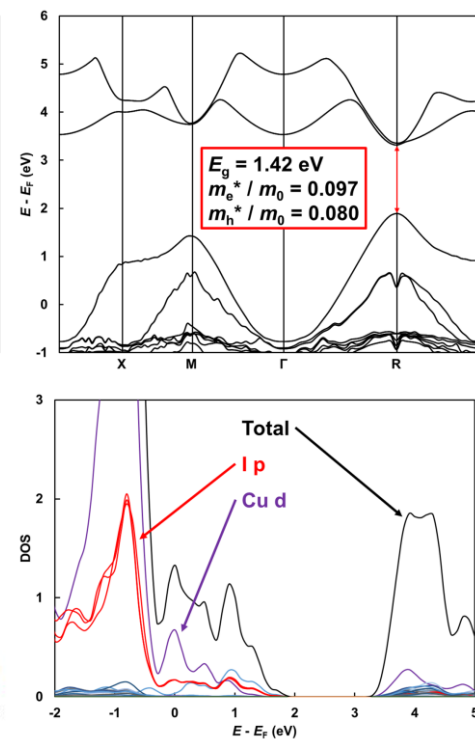
MACuI₃



EAPbI₃



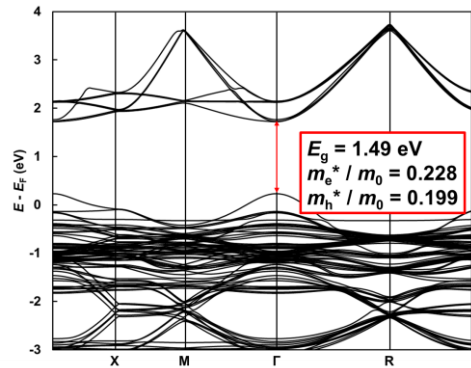
EACuI₃



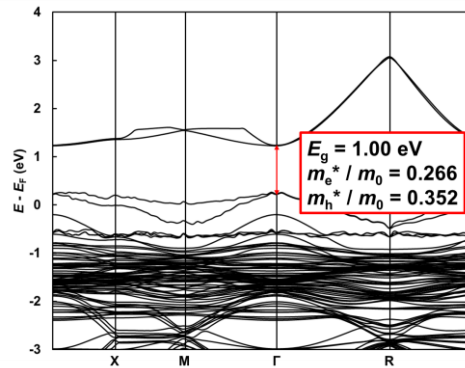
Model	Total energy (keV)	Energy gap (eV)	m_e^* / m_0	m_h^* / m_0
NaPbI ₃	-2.99	1.06	0.077	0.062
MACuI ₃	-2.52	1.48	0.136	0.079
EAPbI ₃	-3.68	1.43	0.076	0.104
EACuI ₃	-2.71	1.42	0.097	0.080

Supporting information

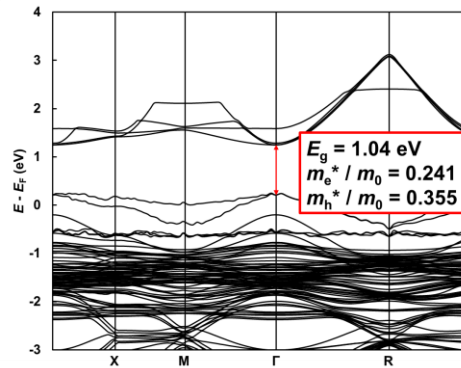
EA 12.5 %



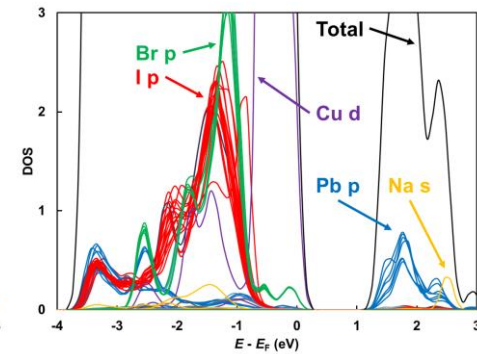
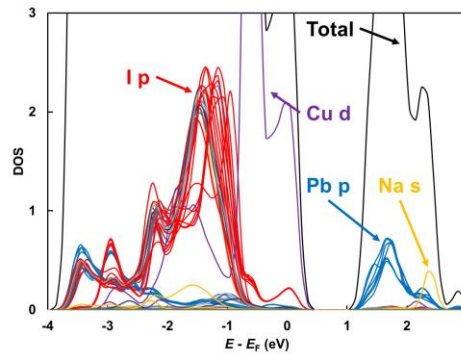
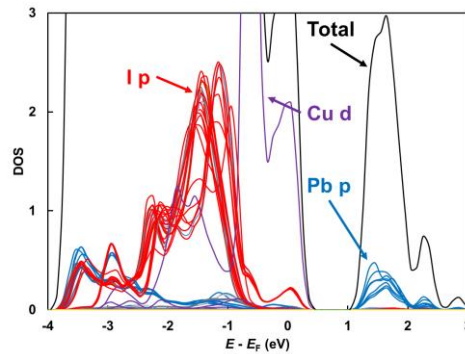
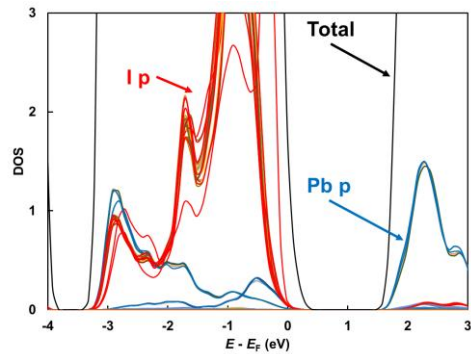
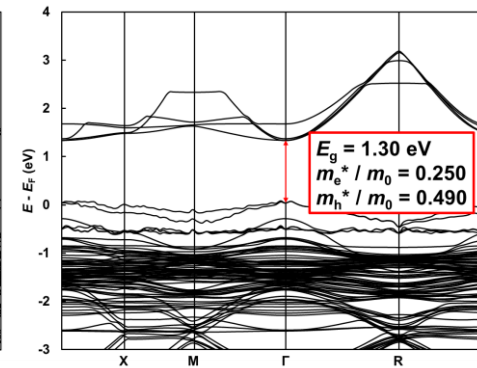
EA Cu 12.5 %



EA Cu Na 12.5 %

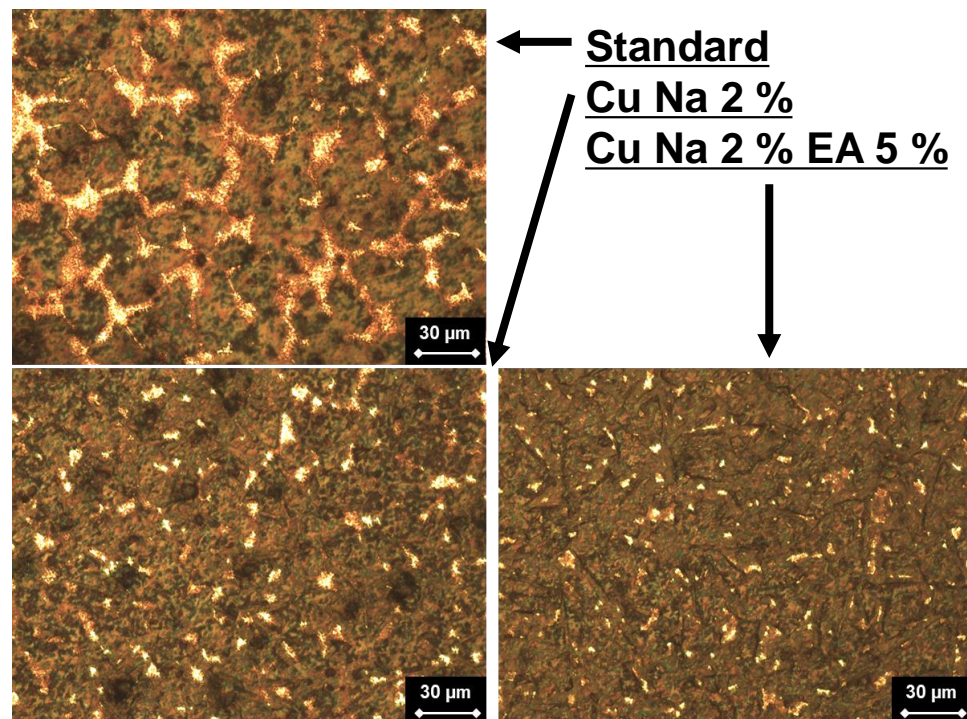
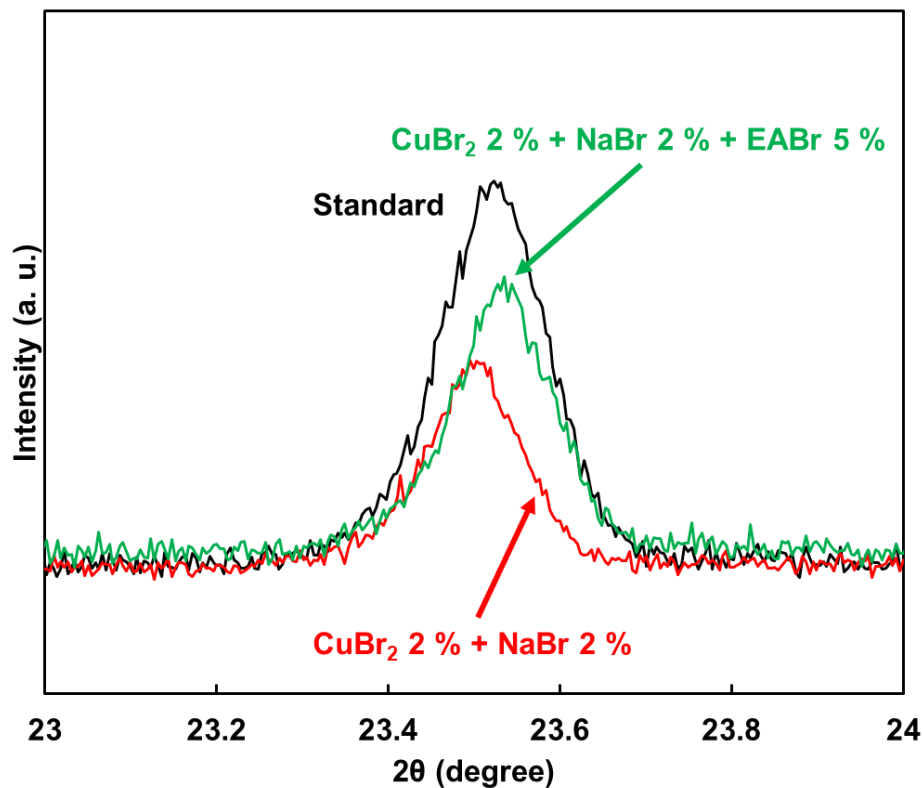


EA Cu Na 12.5 % Br 25 %



Model	Total energy (keV)	Energy gap (eV)	m_e^*/m_0	m_h^*/m_0
EA 12.5 %	-3.52	1.49	0.228	0.199
EA Cu 12.5 %	-3.39	1.00	0.266	0.352
EA Cu Na 12.5 %	-3.32	1.04	0.241	0.355
EA Cu Na 12.5 % Br 25 %	-3.36	1.30	0.250	0.490

Supporting information



Devices	I_{100}/I_{210}	Lattice constant (Å)	Crystallite size (Å)	I_{211} (tetragonal)
Standard	8.7	6.262(1)	697	1.00
CuBr ₂ 2 % NaBr 2 %	2.6	6.271(1)	679	0.60
CuBr ₂ 2 % NaBr 2 % EABr 5 %	3.1	6.261(1)	674	0.81